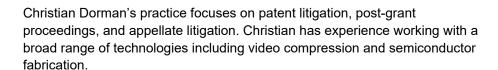
DESMARAIS

Christian Dorman

Associate, Washington, D.C.

PHONE: 202-451-4918 FAX: 202-451-4901

cdorman@desmaraisllp.com



Before joining the firm, Christian clerked for the Hon. Todd M. Hughes at the U.S. Court of Appeals for the Federal Circuit. He later clerked in the District of Delaware for the Hon. Richard G. Andrews and the Hon. Maryellen Noreika.

During law school, Christian worked as a patent examiner at the United States Patent and Trademark Office, where he focused on applications related to the use of error correcting codes in data transmission and storage.

Christian has also represented pro bono clients as part of the Veterans Consortium Pro Bono Program. He recently helped secure benefits for a veteran's widow after the VA had repeatedly denied a benefits claim tied to her husband's bladder cancer and Agent Orange exposure in Vietnam.

Prior Experience

- Associate, Desmarais LLP, New York, 2020-2021
- Summer Associate, Desmarais LLP, New York, 2018

Clerk & Government Experience

- Law Clerk to the Hon. Richard G. Andrews, United States District Court for the District of Delaware, 2022
- Law Clerk to the Hon. Maryellen Noreika, United States District Court for the District of Delaware, 2021–2022
- Law Clerk to the Hon. Todd M. Hughes, U.S. Court of Appeals for the Federal Circuit, 2019–2020
- Patent Examiner & Primary Patent Examiner, United States Patent and Trademark Office, 2013–2019

Courts



EDUCATION

Georgetown University Law Center, J.D., February 2019, magna cum laude, Order of the Coif

Boston University, B.S., Electrical Engineering and Biomedical Engineering, 2013, *cum laude*

ADMISSIONS

2019, District of Columbia

Registered to practice before the United States Patent and Trademark Office

• United States District Court for the District of Columbia

Memberships & Affiliations

- PTAB Bar Association
- Giles S. Rich American Inn of Court

Publications

• "One if by Land, Two if by Sea": The Federal Circuit's Oversimplification of Computer Data Processing, U. III. J.L. Tech. & Pol'y (2018).